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TIP₅: An unexplored direct band gap 2D semiconductor with ultra-high carrier mobility

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Abstract

Two-dimensional materials with a proper band gap and high carrier mobility are urgently desired in the field of nanoelectronics. We propose a novel two-dimensional crystal monolayer TIP₅, which is dynamically and thermodynamically stable and possesses a direct band gap of 2.02 eV with high carrier mobilities ($13960 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ for electrons and $7560 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ for holes), comparable to that of phosphorene. The band gap value and band characteristics of monolayer TIP₅ can be adjusted by biaxial and uniaxial strains, and excellent optical absorption over the visible-light range is predicted. These properties, especially for the balanced high mobilities for not only the electrons but also the holes, render monolayer TIP₅ an exciting functional material for future nanoelectronics and optoelectronic applications.

Keywords: 2D materials, thallium penta-phosphorus, monolayer TIP₅, mobility, electronic properties, phosphorene, density functional theory

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Introduction

Since the successful mechanical exfoliation of graphene in 2004,^{1,2} two-dimensional (2D) materials such as silicene,³ borophene,^{4,5} phosphorene,^{6,7} and transitional metal dichalcogenides (TMDCs)^{8–11} have attracted intensive interests because of their extraordinary electrical, mechanical and thermal properties that enable extensive application potential in various fields.^{9,12–18} For example, phosphorene, with a direct 2.0 eV band gap as well as a high carrier mobility of about $1.14 \times 10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ — $2.60 \times 10^4 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, has been considered to be a candidate for high performance field effect transistors.⁶ Yet, its chemical instability under ambient conditions and the low electron mobility still hinder its practical application. MoS₂ possesses a suitable direct band gap (1.8 eV) for microelectronic and optoelectronic applications, but it suffers from the low carrier mobility ($\sim 200 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$). Nowadays, 2D materials with a proper band gap and high carrier mobilities for both electrons and holes are still urgently desired for logic and optoelectronic devices.

Very recently, a series of 2D phosphides, such as InP₃,¹⁹ GeP₃,²⁰ SnP₃,²¹ and CaP₃,²² have been theoretically proposed as novel 2D semiconductors with high carrier mobilities ($\sim 10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ — $10^4 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) that are comparable to those of phosphorene. In addition, their theoretical cleavage energy is relatively low (0.57–1.32 J m⁻²), indicating that they can be obtained through mechanical exfoliation from bulk. On the other hand, a layered material composed of P and TI with the TIP₅ stoichiometry was already reported in 1971 by Olofsson *et al.*²³ Experimentally, TIP₅ single crystal can be obtained under simple and easy synthetic conditions, which facilitates its mass production. However, there has been no relevant researches published on monolayer TIP₅ yet, and it is highly worthwhile to obtain a comprehensive understanding of the monolayer form.

In this work, we report a new monolayer phosphide, namely, 2D TIP₅ with a unique structure and high dynamic and thermal stability, using first-principles calculations. In addition, TIP₅ shows remarkably weak interlayer interactions, which result in a relatively low cleavage energy of 0.39 J m⁻². Our calculations suggest that TIP₅ monolayer is a semiconductor with 2.02 eV direct band gap. Moreover, it possesses remarkably high carrier mobilities of $13960 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ and $7560 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ for electrons and holes, respectively. It also shows strong light absorption in the visible-light and infrared regions, which is useful for optoelectronic devices.

Results and discussion

As shown in Figures 1a–1c, the symmetry for bulk TIP₅ is orthorhombic with space group *Pmc*2₁, and the unit cell consists of four TIP₅ formula units. Our optimized lattice parameters of bulk TIP₅ are $a = 6.48 \text{ Å}$, $b = 7.01 \text{ Å}$ and $c = 12.24 \text{ Å}$, in good accordance with the experimental results ($a = 6.46 \text{ Å}$, $b = 6.92 \text{ Å}$ and $c = 12.12 \text{ Å}$).²³ In bulk TIP₅, the P atoms are connected to each

Figure 1 (a) Top and side views (along *c* and *b* directions) of optimized bulk TIP₅ with 2×3×2 supercell, respectively. The unit cell is marked in light blue squares. (d) Calculated electronic band structures of bulk TIP₅ using GGA-PBE and HSE06, respectively. The Fermi levels are set to zero energy.

other in a two dimensional network which is parallel to the (010) plane, while the two non-equivalent Tl atoms are bonded to their two neighboring P atoms in the same phosphorus layer. The phosphorus network existing in TIP₅ is very similar to that observed in the monoclinic modification of Hittorf's phosphorus²⁴ (see Figures S2 and S3 for details, Supporting Information). Thus, TIP₅ may be regarded as a particular 'phosphorene' whose surface has been passivated by metal thallium. The unique structural properties of TIP₅ may bring about distinct material characteristics. In addition, bulk TIP₅ is an indirect band gap semiconductor with a band gap value calculated to be 1.14 eV and 1.72 eV at the PBE and HSE06 levels (Figure 1d), respectively.

Monolayer TIP₅ was obtained in our calculation by taking an atomic layer from bulk TIP₅ along the (010) direction. As shown in Figure 2a, its structural characteristics remain, exhibiting a rectangular configuration. The optimized lattice parameters of monolayer TIP₅ are *a* = 12.35 Å and *b* = 6.51 Å. The P-P bond length is 2.16 Å to 2.24 Å, shorter than that of phosphorene (2.24 Å to 2.28 Å), while the Tl-P bond length is 3.00 Å to 3.17 Å (see Table S1, Supporting Information). As is well known, mechanical cleavage^{1,6} and liquid phase exfoliation²⁵ are powerful techniques to produce single and few layer flakes from the layered bulk materials. To assess such possibility we have calculated the cleavage energy of monolayer TIP₅ from a five-layer TIP₅ slab, mimicking the

Figure 2 (a) Top view of the optimized monolayer TIP₅ and the corresponding first Brillouin zone with high symmetry points. (b) Cleavage energy estimation for the formation of monolayer TIP₅, calculated by enlarging the interlayer distance between the monolayer system that is removed from the remainder of a five-layer slab, resembling the bulk model. (c) The calculated phonon dispersion spectra and phonon density of states of the monolayer TIP₅.

bulk. As shown in Figure 2b, the cleavage energy increases with the interlayer distance, but reaching a convergence of about 0.39 J m⁻². The estimated exfoliation energies of graphene and black phosphorus are, respectively, 0.32 J m⁻² and 0.37 J m⁻² according to our calculation, which are in line with previous theoretical studies.^{19,26} The DFT-estimated exfoliation energies for some other layered phosphides such as InP₃,¹⁹ GeP₃,²⁰ CaP₃,²² and SnP₃²¹ are 1.32 J m⁻², 1.14 J m⁻², 1.30 J m⁻² and 0.57 J m⁻², respectively. Therefore, exfoliation from the bulk is feasible for monolayer TIP₅ preparation, as its cleavage energy is comparable with the mentioned 2D materials above.

In addition, the phonon dispersions of monolayer TIP₅ (shown in Figure 2c) consist of only real modes whose styles are typical for 2D crystals, indicating the kinetic stability. The highest frequency mode of monolayer TIP₅ reaches 477 cm⁻¹, which is very close to that of MoS₂ (473 cm⁻¹)²⁷ and higher than that of phosphorene (~450 cm⁻¹)¹⁶, revealing the mechanical robustness of the covalent P-P bonds. The thermal stability is further substantiated by *ab initio* molecular dynamics (AIMD) simulations (see Figure S5, Supporting Information), where the monolayer TIP₅ structure remains intact at 300 K after a 5 ps simulation time.

Subsequently, we studied the electronic band structures of monolayer TIP₅. Since Te is a heavy element, the spin-orbit coupling (SOC) effect may affect the electronic properties of monolayer TIP₅. The band structures of monolayer TIP₅ with and without SOC were both calculated, using either the PBE functional or the HSE06 hybrid functional. As shown in Figure 3a, using GGA-PBE without considering SOC, the band gap of TIP₅ is predicted to be a 1.37 eV direct one. A similar band structure but with a larger direct band gap of 2.02 eV has been confirmed based on HSE06 calculations. We then examine the effect of SOC in our calculations. The conduction band minimum (CBM) and valence band maximum (VBM) of monolayer TIP₅ do not

Figure 3 (a) Electronic band structures of monolayer TIP_5 calculated using GGA-PBE and HSE06 without considering SOC. (b) Computed band gaps of TIP_5 multilayers versus the number of atomic layers, using GGA-PBE and hybrid HSE06 functionals, respectively.

show discernable shift after turning on the SOC, regardless of using PBE or HSE06. For the band gap, the difference is less than 0.01 eV with and without SOC (Figures S6a and S6b, Supporting Information). The negligible impact of SOC indicate that it is the P 3p orbitals that contribute most to the VBM and CBM states, as can be confirmed by the wave functions and partial density of states (PDOS) results (shown in Figures S7a and S7b, Supporting Information). Therefore, we shall neglect the SOC effect in all forthcoming band structure calculations.

In order to elucidate the changes in the electronic properties of TIP_5 from the bulk to few layers, we have investigated the electronic band gaps of 2D TIP_5 with varying number of layers, where the results are shown in Figure 3b and Figure S8 (Supporting Information). The electronic structures of 2D TIP_5 multilayers indeed strongly depend on the number of layers. The bi-layer and tri-layer TIP_5 still maintain the direct band gap feature, similar to the monolayer TIP_5 . However, the four-layer TIP_5 (Figure S8c, Supporting Information) shows a direct-to-indirect band gap transition with the VBM shifted from Y to A (which lies along the Y- Γ direction), though the CBM remains at the Y-point. The five-layer TIP_5 remains as an indirect band gap semiconductor (Figure S8d, Supporting Information). The possible reasons for losing the direct gap feature are the lacking of interlayer interaction, and structural reconstruction upon stacking atomic layers.²²

In order to explore the application potential of monolayer TIP_5 in electronic devices, we systematically calculated the carrier mobility (electrons and holes) based on the deformation potential (DP) theory proposed by Bardeen and Shockley.²⁸ The carrier mobility of 2D materials

can be evaluated by the following equation^{22,29,30} $\mu_{2D} = \frac{e\hbar^3 C_{2D}}{k_B T m^* m_d (E_1^i)^2}$, where $\hbar$ is the reduced

Planck constant, k_B is the Boltzmann constant, m^* is the effective mass in the direction of

Carrier type	m_a^*	m_b^*	$ E_{1a} $	$ E_{1b} $	C_a^{2D}	C_b^{2D}	μ_a^{2D}	μ_b^{2D}
electrons	0.480	0.645	0.574	0.614	21.59	88.49	5.24	13.69
holes	0.886	0.215	0.397	3.647	21.59	88.49	7.56	1.51

Table 1 Calculated effective mass m^* (unit: m_e), deformation potential constant $|E_1^i|$ (unit: eV), elastic modulus C_{2D} (unit: N m^{-1}), and carrier mobility μ_{2D} (unit: $10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) of TIP_5 monolayer along the a (Y - S) and b (Y - Γ) directions.

transport, m_d is the average effective mass determined by $m_d = (m_a^* m_b^*)^{1/2}$, and T is the temperature ($T = 300 \text{ K}$). The elastic modulus C_{2D} of the longitudinal strain in the propagation direction is derived from $(E - E_0) / S_0 = C_{2D} (\Delta l / l_0)^2 / 2$, where E is the total energy of the 2D structure, and S_0 is the lattice area of the equilibrium supercell. The deformation potential constant E_1^i is defined as $E_1^i = \Delta E_i / (\Delta l / l_0)$. Here ΔE_i is the energy change of the i^{th} band under proper cell compression and dilatation (calculated using a step of 0.25%), l_0 is the lattice constant in the transport direction and Δl is the deformation of l_0 .

As summarized in Table 1, the elastic moduli are obviously anisotropic with the value of 21.59 N m^{-1} and 88.49 N m^{-1} along the a and b directions, respectively. These are slightly lower than those of phosphorene ($C_x = 29 \text{ N m}^{-1}$ and $C_y = 102 \text{ N m}^{-1}$)²⁹. The effective masses of both electron and hole along the a/b directions are anisotropic as well. Especially for the hole, the effective mass along a direction ($0.886 m_e$) is notably larger than that along the b direction ($0.215 m_e$). The deformation potential E_1 is nearly the same for the electron (0.574 eV along a and 0.614 eV along b), but exhibits a strong anisotropy for the hole (similar to hitorfene²⁴, phosphorene²⁹ and CaP_3 ²²) with that of the b direction having the smallest value of about 0.397 eV. This contributes to a very large hole mobility along the a direction, up to $7.56 \times 10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$. Note that the electron mobility along b direction points to an even larger value of $1.396 \times 10^4 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, which is because of the joint action of a large elastic modulus and a small deformation potential along the b direction. It is also noteworthy that even the lower electron mobility in a direction ($5.24 \times 10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) and hole mobility in b direction ($1.51 \times 10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) are of similar order of magnitude compared with other 2D phosphides, while much larger than that of most 2D TMDCs³¹.

Compared with phosphorene and their derivatives reported recently, monolayer TIP_5 possesses one of the most attractive electronic properties (see Table S3, Supporting Information). Traditionally, phosphorene and their derivatives have either high hole mobility combined with low electron mobility, or vice versa. For instance, monolayer CaP_3 has a high electron mobility of

Figure 4 Electronic band gaps of monolayer TIP₅ under various strains, calculated using screened HSE06 hybrid functional.

$1.99 \times 10^4 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, whereas its hole mobility is only $0.78 \times 10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$.²² However, high hole and electron mobilities of nearly or more than the order of $10^4 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ can be achieved simultaneously in monolayer TIP₅, which is of great significance for improved device performance. Furthermore, the structure of 2D TIP₅ is different from the reported 2D InP₃ or CaP₃.^{19,22} There is a continuous framework of P in TIP₅, involving two different P clusters, *i.e.* P₆ and P₅. Besides, anisotropic structures also lead to anisotropic electronic structures and mechanical properties as already discussed. Note that the monolayer TIP₅ possesses a direct band gap of 2.02 eV (calculated using HSE06, where the same criteria follow below), much higher than that of InP₃ (indirect, 1.14 eV), GeP₃ (indirect, 0.55 eV), CaP₃ (direct, 1.15 eV), SnP₃ (indirect, 0.72 eV) and phosphorene (direct, 1.51 eV). Therefore, monolayer TIP₅ would be particularly suitable for nanoelectronic and optoelectronic applications.

Since applying elastic strain is an effective means of band structure engineering in 2D semiconductors,^{14,32} we further studied the effects of in-plane compressive/tensile biaxial and uniaxial strains on the band structures of monolayer TIP₅. Figure 4 presents the HSE06-predicted band gaps of TIP₅ monolayer under different strains in the range of -6% to 6% (the band structures are plotted in Figure S10, Supporting Information). Interestingly, the band gaps of TIP₅ monolayer increase gradually with either compressive or tensile uniaxial strains along *a* axis, and the direct band gap feature remains unchanged within the range of strain being considered (see Figure S10a, Supporting Information). On the other hand, under the biaxial strain and the uniaxial strain along *b* axis, the band gap value demonstrates a similar variation trend, *i.e.*, increasing linearly until up to 2%, and then both decreasing linearly. A direct-to-indirect band gap transition has been discovered when the tensile strain reaches 3% for both biaxial and uniaxial strains along *b* axis. The position of the VBM is located at the Y-point while the CBM has shifted from Y to Γ (see Figures S10b and S10c, Supporting Information). The indirect band gap feature is maintained

Figure 5 Calculated in-plane ((a) and (b)) and out-plane (c) light absorption coefficients of monolayer TIP_5 , using the screened HSE06 hybrid functional.

with the continuous increase of strain. The variable responses to the strain in monolayer TIP_5 may be of interest for certain mechanical applications.

The direct band gap feature of monolayer TIP_5 allows it to be directly coupled to light, like phosphorene.⁶ Hence, we further explored the optical properties of TIP_5 monolayer by calculating the absorption spectra in- and out-of-plane using the HSE06 functional. The transverse dielectric function $\epsilon(\omega) = \epsilon_1(\omega) + i\epsilon_2(\omega)$ is used to describe the optical properties of materials,³³ where ω is the photon frequency, $\epsilon_1(\omega)$ is the real part and $\epsilon_2(\omega)$ is the imaginary part of the dielectric function, respectively. The absorption coefficient can be evaluated according to the expression³³

$$\alpha(\omega) = \frac{\sqrt{2}\omega}{c} \left\{ \left[\epsilon_1^2(\omega) + \epsilon_2^2(\omega) \right]^{\frac{1}{2}} - \epsilon_1(\omega) \right\}^{\frac{1}{2}}. \text{ As shown in Figure 5, the absorption coefficients of}$$

monolayer TIP_5 reaches the order of 10^5 cm^{-1} , and covering a wide wave-length range in the visible light region. In-plane absorption is always stronger than that of out-of-plane, due to the larger cross section area. In addition, in-plane optical absorption shows obvious anisotropy along the x and y directions, as shown in Figures 5a and 5b. Interestingly, under the applied biaxial compressive strain, both the in-plane and out-plane absorption coefficients are greatly enhanced in the all photon-energy range, which may be attributed to the band gap reduction caused by the strain (see Figure S10c, Supporting Information). However, although the band gap decreases under the biaxial tensile strain as well, a slight reduction in optical absorption has been observed, which may stem from the direct-indirect band gap transition under strain (Figure S10c, Supporting Information). The outstanding optical properties suggest potential applications of monolayer TIP_5 as efficient optical absorber materials in solar cells and optoelectronic devices.

Conclusion

In summary, we have shown that the 2D semiconducting monolayer TIP₅ is a remarkable new candidate for high performance nanoelectronics and optoelectronic devices. Synthesis of the layered bulk semiconductor species has been known since 1971, and the predicted cleavage energies indicate that exfoliation from the bulk is possible. Monolayer TIP₅ shows a direct band gap of 2.02 eV with a quite balanced and outstanding carrier mobilities for electrons ($1.396 \times 10^4 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) and holes ($0.756 \times 10^4 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$), even superior to that of phosphorene. Energy gap characteristics can be modulated for the monolayer by strain engineering. Besides, TIP₅ monolayer has a substantial light absorption in the range of the solar spectrum.

Methods: All density functional theory (DFT) calculations were performed using plane-wave-based Vienna *Ab-initio* Simulation Package (VASP).^{34,35} The generalized gradient approximation (GGA) within the Perdew-Burke-Ernzerhof (PBE)³⁶ functional form was used for the exchange-correlation energy, and projector augmented-wave (PAW) pseudopotentials^{37,38} were used to replace the core electrons. The HSE06 screened hybrid functional³⁵ was used to calculate the band structures in order to correct the band gaps in GGA-PBE. The plane wave energy cutoff was fixed to be 500 eV. The van der Waals (vdW) interactions were corrected by the DFT-D3 approach.³⁹ For all structural relaxations, the convergence criterion for total energy was set to 1.0×10^{-6} eV, and structural optimization was obtained until the Hellmann-Feynman force acting on any atom was less than 0.01 eV/Å in each direction. The phonon dispersion was calculated with the density functional perturbation theory, using the PHONOPY code.⁴⁰ *Ab initio* molecular dynamics (AIMD) simulations were performed to examine the thermal stability of the structures, where NVT canonical ensembles were used.

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Supporting information

First of all, we have checked the stability of bulk TIP₅ through the phonon dispersion calculation. The result in Figure S1 shows only real modes, indicating good dynamic stability.

Figure S1 Calculated phonon dispersion relation of bulk TIP₅.

The phosphorus network founded in TIP₅ is very similar to the one observed in the monoclinic modification of red phosphorus, the so-called Hittorf's phosphorus.¹ As shown in Figure S2, in TIP₅ there are discernable tubes with pentagonal cross-sections, which are very characteristic structure of the phosphorus element in Hittorf's phosphorus. Comparing these two structures, one finds that the phosphorus network in TIP₅ can be regarded as stemming from a partial breaking of the network in Hittorf's phosphorus, as shown in Figure S3.

Figure S2 Demonstration of the crystal structures for: (a) bulk (2×3×2 supercell) TIP₅; (b) bulk (1×2×1 supercell) Hittorf's phosphorus; (c) monolayer (2×2×1 supercell) TIP₅; and (d) monolayer (2×2×1 supercell) Hittorf's phosphorus.

Figure S3 Comparison of the pentagonal tubes in the phosphorus network of (a) Hittorf's phosphorus and (b) TIP_5 . Illustrations of the possible P-P bond breaking schemes are also given.

Figure S4 A schematic diagram of the P-P bonds and TI-P bonds in monolayer and bulk TIP_5 . Only a single formula unit of TIP_5 has been marked.

The bond lengths of P-P and TI-P in both monolayer and bulk TIP_5 are listed in Table S1, together with the experimental results for the sake of comparison. The P-P bond lengths of monolayer TIP_5 are around $2.16 \text{ \AA} \sim 2.27 \text{ \AA}$, while those of TI-P are around $3.0 \text{ \AA} \sim 3.17 \text{ \AA}$. These values are very close to those of optimized bulk TIP_5 ($2.15 \text{ \AA} \sim 2.28 \text{ \AA}$ for P-P bonds and $3.00 \text{ \AA} \sim 3.09 \text{ \AA}$ for TI-P bonds). Most of the P-P and TI-P bond lengths in monolayer TIP_5 are slightly larger than in the bulk, which is as expected.

	1L TIP ₅	Bulk TIP ₅	Exp.
	P-P (Å)	P-P (Å)	P-P (Å)
P1(4)	2.243	2.242	2.242
P2(4)	2.218	2.216	2.213
P3(4)	2.27	2.275	2.229
P4(4)	2.238	2.228	2.222
P5(4)	2.227	2.218	2.225
P6(2)	2.174	2.172	2.174
P7(2)	2.157	2.15	2.126
P8(4)	2.187	2.178	2.13
P9(2)	2.203	2.198	2.221
	P-TI(Å)	P-TI(Å)	P-TI(Å)
TI1(4)	3.17	3.03	2.985
TI2(4)	3.01	3.023	3.015
TI3(2)	3.008	2.998	2.986
TI4(2)	3.04	3.089	3.025

Table S1 The optimized P-P and TI-P bond lengths in the TIP₅ monolayer (“1L” for short) and bulk, respectively, in comparison to the experimentally verified values (Exp.) for the bulk. The numbers in parentheses count the equivalent P-P bonds in a unit cell, and the corresponding bond locations are marked in Figure S4.

Figure S5 Side view of the snapshots from the molecules dynamics simulation for the TIP₅ monolayer. The variation of total energy was recorded during the simulation time of 5 ps, and the temperature was 300 K.

The optimized lattice constants of nL ($n=1, 2, 3, 4, 5$) TiP_5 and bulk are listed in Table S2, with reference to experimental values. The optimized lattice parameters of monolayer TiP_5 are $a = 12.35 \text{ \AA}$ and $b = 6.51 \text{ \AA}$ (note that the a/b here actually correspond to the c/a directions in bulk). Upon the increase in the number of layers, the lattice constants vary very little, indicating a relatively weak interlayer coupling in the TiP_5 system.

Lattice constant	1L	2L	3L	4L	5L	Bulk	Exp. ²
$a/\text{\AA}$	12.35	12.27	12.26	12.26	12.25	6.48	6.46
$b/\text{\AA}$	6.51	6.49	6.49	6.48	6.48	7.01	6.92
$c/\text{\AA}$	--	--	--	--	--	12.24	12.12

Table S2 The optimized lattice constants ($a/b/c$) in TiP_5 monolayer (1L), bilayer (2L), tri-layer (3L), four-layer (4L), five-layer (5L) and bulk, respectively, in comparison to the experimental values (Exp.) for the bulk.

Figure S6 (a) Band structures of monolayer TiP_5 calculated using the PBE functional, either with or without considering the effect of spin orbit coupling (SOC). (b) Band structures of monolayer TiP_5 calculated using the screened HSE06 hybrid functional, either with or without considering the effect of SOC.

Figure S7 (a) Projected density of states of monolayer TIP₅. (b) Isosurfaces of partial charge densities corresponding to the VBM and CBM of monolayer TIP₅.

Figure S8 Electronic band structures of 2D TIP₅ with varying number of layers, calculated using the screened HSE06 hybrid functional: (a) bilayer; (b) trilayer; (c) four-layer; and (d) five-layer.

Figure S9 (a) The relationship between total energy and the applied strain δ along the a and b directions of monolayer TIP_5 . The quadratic data fitting gives the in-plane stiffness of 2D structures. Black and red curves show the in-plane stiffness along the a and b directions of monolayer TIP_5 , respectively. (b) The shift of VBMs and CBMs for monolayer TIP_5 with respect to the vacuum energy, as a function of the applied strain along either the a or the b direction. The linear fit of the data yields the deformation potential constant.

	Direction	TIP_5	Phosphorene ³	Hittorfene ¹	InP_3 ⁴	GeP_3 ⁵	CaP_3 ⁶	SnP_3 ⁷
Electron	x	5.24	1.10-1.14	0.50	0.54	0.04	19.9	0.19
	y	13.96	0.08	0.43	1.92	0.07	1.75	0.21
Hole	x	7.56	0.64-0.70	0.31	0.006	0.014(0.35)	0.08	0.17
	y	1.51	10-26	7.68	0.05	0.19(2.36)	0.78	0.36
Band gap		2.02(d)	1.51(d)	2.5(d)	1.14(i)	0.55(i)	1.15(d)	0.72(i)

Table S3 The carrier mobilities μ_{2D} ($\times 10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) and energy band gaps (eV, calculated at the HSE06 level) of phosphorene and their derivatives for comparison (only the monolayer is considered). The symbols d and i represent direct and indirect band gaps, respectively.

Uniaxial strain along a

Uniaxial strain along b

Figure S10 Electronic band structures of monolayer TIP_5 under various strain situations, calculated using the HSE06 functional. The applied strains are (a) uniaxial strain along a -axis; (b) uniaxial strain along b -axis; and (c) biaxial along both a and b .

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